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U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM 10019278	FILING DATE 01/02/2002	CLASS 210 255	SUBCLASS 425	GAU 1723 288	EXAMINER Mark Hou
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**CONTINUING DATA VERIFIED: THIS APPLICATION IS A 371 OF PCT/FR00/01827 06/29/2000 WA					
** FOREIGN APPLICATIONS VERIFIED: FRANCE 99/33473 07/01/1999 WA					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input checked="" type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO			
35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no		217218US2PCT			
Verified and Acknowledged Examiners's initials					
TITLE : Method and device for electronic cyclotron resonance plasma deposite of carbon nanofibre layers in fabric form and resulting fabric layers					
U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-92)					

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	
		Print Claim for O.G.	
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg.
		Print Fig.	
Primary Examiner		Application Examiner	
PREPARED FOR ISSUE			
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